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Date of Mailing April 22, 2004

PATENT
Case No. **P1315 US**
(2650/56)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

MARK BRISTER

Serial No.

Examiner:

Filed:

Group Art Unit:

Title: METHOD OF TREATING VULNERABLE
PLAQUE USING A CATHETER-BASED
RADIATION SYSTEM

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22202-1450

Dear Sir:

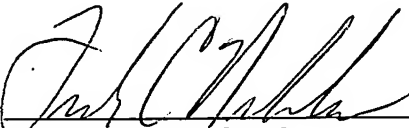
Pursuant to 37 C.F.R. §§ 1.56 and 1.97-1.98, Applicant would like to call the Examiner's attention to the references listed on the enclosed form PTO-1449.

Applicant believes that none of the listed references, alone or in combination disclose or suggest Applicant's claimed invention.

Dated: April 22, 2004

Respectfully submitted,

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FORM PTO-1449	SERIAL NO.	CASE NO. P1315 US (2650/56)
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (use several sheets if necessary)	FILING DATE	GROUP ART UNIT
		APPLICANT(S): MARK BRISTER

REFERENCE DESIGNATION			U.S. PATENT DOCUMENTS			
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS/ SUBCLASS	FILING DATE
	A1	6,475,210	11/05/2002	PHELPS ET AL.		
	A2	6,475,159	11/05/2002	CASCELLS ET AL.		
	A3	6,377,846 B1	04/23/2002	CHORNENKY ET AL.		
	A4	6,338,709 B1	01/15/2002	GEOFFRION ET AL.		
	A5	5,924,997	07/20/1999	CAMPBELL		
	A6	5,503,613	04/02/1996	WEINBERGER		
	A7	5,484,384	01/16/1996	FEARNOT		
	A8	5,213,561	05/25/1993	WEINSTEIN ET AL.		

FOREIGN PATENT DOCUMENTS						
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS/ SUBCLASS	TRANSLATION YES NO

EXAMINER INITIAL	OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)	

EXAMINER	DATE CONSIDERED
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.